

Docket Number: 071469-0306511
Client Reference: PC6025A

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re the Application of

ARTHUR H LAFLAMME, JR., et al.

Group Art Unit:

Application No.:

Examiner:

Filed: December 17, 2003

Confirmation No.:

For: A REDUCED MAINTENANCE CHEMICAL OXIDE REMOVAL (COR)
PROCESSING SYSTEM

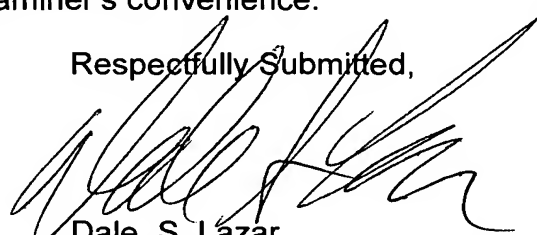
INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

Sir:

This application is one of a series of related applications, identified in the attached Appendix, which are directed to related technical subject matter. The identification of those U.S. Patent Applications is not to be construed as a waiver of secrecy as to those applications now or upon issuance of the present application as a patent. The Examiner is respectfully requested to consider the cited applications and the art cited therein during examination. A non-provisional application has been filed for each of the listed provisional applications in the first paragraph of the specification - the application serial numbers and filing dates are listed in the attached table and copies of each of the non-provisional applications are provided for the Examiner's convenience.

Respectfully Submitted,



Dale S. Lazar
Registration Number 28872

Customer Number: 00909

Date: December 17, 2003
PILLSBURY WINTHROP LLP
Telephone: (703) 905-2000
Facsimile: (703) 905-2500
P.O. Box 10500
McLean, VA 22102

APPENDIX

Examiner's Initials	First Inventor	Application No.	Filing Date	Enclosure
	HAMELIN	60/457,597 10/705,201	3/17/03 11/12/03	Spec. and dwgs. for non-prov. Appln.
	HAMELIN	60/454,642 10/705,200	3/17/03 11/12/03	Spec. and dwgs. for non-prov. Appln.
	HAMELIN	60/454,641 10/704,969	3/17/03 11/12/03	Spec. and dwgs. for non-prov. Appln.
	WALLACE	60/454,644 10/705,397	3/17/03 11/12/03	Spec. and dwgs. for non-prov. Appln.

The Examiner's initials indicates he/she has considered the cited application relative to the subject application.

DO NOT PRINT the above information on the patent which results from the subject application.